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***Plasmonics: Design, Materials,  
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and Applications XVIII***

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Takuo Tanaka**  
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# Contents

v *Introduction*

---

## PLASMONIC/NANOPHOTONIC DEVICES I

---

11462 0F **Reduction of plasmon linewidth in dispersive absorbing media [11462-13]**

---

## EMITTING DEVICES

---

11462 0M **Fast modulation and polarization control of infrared emission by incandescent metasurfaces (Invited Paper) [11462-20]**

11462 0N **Enhancement of exciton emission in a semiconductor thin film decorated with plasmonic nanoparticles [11462-21]**

---

## FUNDAMENTALS OF PLASMONICS I

---

11462 0V **Scattering electromagnetic eigenstates of a two-constituent composite where both the electric permittivity and the magnetic permeability are nonuniform (Invited Paper) [11462-29]**

11462 0W **Electromagnetic radiation and the self torque of an oscillating magnetic dipole (Invited Paper) [11462-30]**

---

## METASURFACES

---

11462 19 **Meta-structure assisted plasmonic nano-tweezers (Invited Paper) [11462-43]**

---

## FUNDAMENTALS OF PLASMONICS II

---

11462 1C **Machine learning for the design of nanomaterials (Invited Paper) [11462-46]**

---

## PLASMONIC SENSING II

---

- 11462 1Q **Application of self-assembled plasmonic structures for microfluidic control and sensing (Invited Paper)** [11462-60]
- 11462 1R **Limits to surface-enhanced Raman scattering near arbitrary-shape scatterers** [11462-61]

---

## FUNDAMENTALS OF PLASMONICS III

---

- 11462 1W **Modes interplay controls the second harmonic generation dynamics of plasmonic nanostructures** [11462-65]

---

## POSTER SESSION

---

- 11462 1Y **Surface plasmon-polariton waves obliquely guided along interface containing periodicity direction of one-dimensional photonic crystal** [11462-67]
- 11462 20 **Synthesis and nonlinear optical properties of bimetallic nanoparticles** [11462-69]
- 11462 21 **Stimulated Raman and Brillouin scattering on a plasma layer and bodies with complex shape** [11462-70]
- 11462 22 **Design and testing of ultrafast plasmonic lens nanoemitters** [11462-71]
- 11462 23 **Current-driven optical response of plasmonic crystal: From dissipation to amplification** [11462-72]
- 11462 2A **Near-infrared high sensitivity solute concentration sensor based on lossy-mode resonance of multimode fiber structures coated with aluminum-doped zinc oxide** [11462-79]
- 11462 2B **Plasmonically enhanced photobrightening using quantum dots** [11462-80]
- 11462 2M **Modeling and simulation of evanescent coupling to Si waveguides using SPP** [11462-91]
- 11462 2T **Design of nanoantenna for magnetic field enhancement** [11462-98]
- 11462 2Y **Plasmonic computational lithography for below 10-nm patterning** [11462-103]
- 11462 2Z **Near zero index THz perfect metasurface absorber using inverted conformal mapping** [11462-104]
- 11462 32 **Design and modeling of novel plasmonic switches based on phase change materials** [11462-108]